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WPI Acc No: 1966-02417F/196800

Skin treatment composition

Patent Assignee: HELLBBAUM AA (HELB)

Number of Countries: 002 Number of Patents: 002

Patent Family:

Patent No	Kind	Date	Applicat No	Kind	Date	Week
GB 859546	A					196800 B
US 3198702	A					196801

Abstract (Basic): GB 859546 A

Skin treatment composition for topical therapeutic use, comprising 0.001-1 mg/g of the composition of e.g., 3,5 - diiodo - 4(41 - hydroxy - 31 - iodo - phenoxy) phenyl acetic acid, where R1 = halogen, R2 = H or halogen, R3 and R4 = hydrogen, halogen, C1-3 alkyl, R4 = H, C1-3 alkyl or acyl, R6 = H or lower alkyl, A = alkylene, substituted alkylene, etc., in a powder or cream base.

Title Terms: SKIN; TREAT; COMPOSITION

Derwent Class: B00

File Segment: CPI

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